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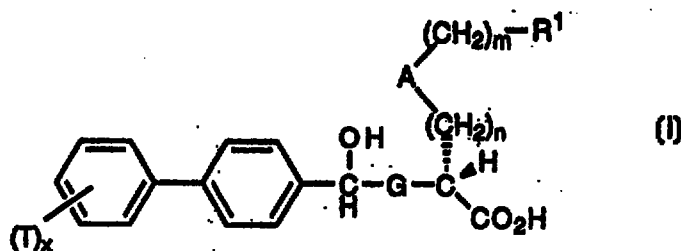
PCT

WORLD INTELLECTUAL PROPERTY ORGANIZATION
International Bureau

INTERNATIONAL APPLICATION PUBLISHED UNDER THE PATENT COOPERATION TREATY (PCT)

(51) International Patent Classification ⁶ : C07C 323/56, 323/61, 323/62, 59/48, 59/56, 235/84, C07D 209/48, A61K 31/19, C07C 271/22, A61K 31/40	A1	(11) International Publication Number: WO 98/22436 (43) International Publication Date: 28 May 1998 (28.05.98)
(21) International Application Number: PCT/US97/19960 (22) International Filing Date: 30 October 1997 (30.10.97) (30) Priority Data: 60/030,264 31 October 1996 (31.10.96) US (71) Applicant: BAYER CORPORATION [US/US]; 100 Bayer Road, Pittsburgh, PA 15205 (US) (72) Inventors: KLUENDER, Harold, C., E.; 27 Academy Road, Trumbull, CT 06611 (US); BJORGE, Susan, M.; 5 Brownstone Road, Wallingford, CT 06492 (US); ZADJURA, Lisa, Marie; 16 Sea Lane, Old Saybrook, CT 06475 (US); BRUBAKER, William, Frederick; 116 Nob Hill Road, Cheshire, CT 06410 (US). (74) Agents: GREENMAN, Jeffrey, M. et al.; Bayer Corporation, 400 Morgan Lane, West Haven, CT 06516 (US).		(81) Designated States: AL, AM, AT, AU, AZ, BA, BB, BG, BR, BY, CA, CH, CN, CZ, DE, DK, EE, ES, FI, GB, GE, GH, HU, IL, IS, JP, KE, KG, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MD, MG, MK, MN, MW, MX, NO, NZ, PL, PT, RO, RU, SD, SE, SG, SI, SK, SL, TJ, TM, TR, TT, UA, UG, UZ, YU, ZW, ARIPO patent (GH, KE, LS, MW, SD, SZ, UG, ZW), Eurasian patent (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European patent (AT, BE, CH, DE, DK, ES, FI, FR, GB, GR, IE, IT, LU, MC, NL, PT, SE), OAPI patent (BF, BJ, CF, CG, CI, CM, GA, GN, ML, MR, NE, SN, TD, TG). Published With international search report.

(54) Title: SUBSTITUTED 4-BIPHENYL-4-HYDROXYBUTYRIC ACID DERIVATIVES AS MATRIX METALLOPROTEASE INHIBITORS



(57) Abstract

Inhibitors for matrix metalloproteases, pharmaceutical compositions containing them, and a process for using them to treat a variety of physiological conditions. The compounds of the invention have generalized formula (I) in which T is a pharmaceutically acceptable substituent group; A is CH₂, CH, or N; G is CH₂ or CH; and R¹ is any of a variety of disclosed substituent groups. The class of compounds of the invention includes ring-containing materials in which the units A and G are joined. The compounds of the invention are mixtures of diastereomers, or individual diastereomers making up these mixtures.